

Abstract of the Disclosure:

Transparent laminates which have high transparency and, moreover, excellent electromagnetic shielding characteristics and near-infrared cutting-off characteristics, and optical filters for displays using these transparent laminates. These transparent laminates are formed by laminating a transparent electrically conductive layer composed of high-refractive-index transparent film layers (B) and metal film layers (C) consisting of silver or a silver-containing alloy on one major surface of a transparent substrate (A) in such a way that a repeating unit comprising a combination of one high-refractive-index transparent film layer (B) and one metal film layer (C) is laminated three times or more, and further laminating one high-refractive-index transparent film layer (B) thereon. The transparent laminate has a sheet resistance of not greater than $3 \Omega/\text{sq.}$, a visible light transmittance of not less than 50%, and a light transmittance of not greater than 20% in a wavelength region longer than 820 nm. Optical filters for displays which serve to block leakage electromagnetic waves and near-infrared light from plasma displays can be acquired by using such a transparent laminate.



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